



**Irfu - CEA Saclay**

Institut de recherche  
sur les lois fondamentales  
de l'Univers

DE LA RECHERCHE À L'INDUSTRIE



## 2<sup>nd</sup> ATTRACT TWD Symposium in Detection and Imaging

4-5 November 2016  
Strasbourg

# *Thermal neutron detection with high efficiency and high granularity, using large area Micromegas detectors*

T. Papaevangelou, A. Delbart, A. Menelle, G. Tsiledakis

CEA Saclay

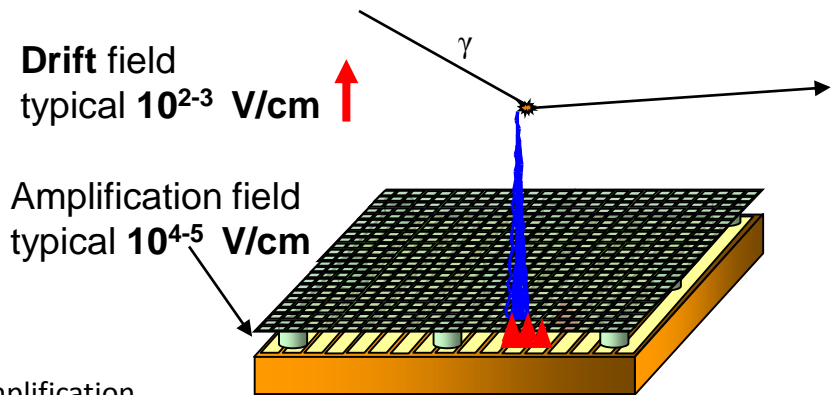
# Micromegas concept

Two-region gaseous detector  
*separated by a Micromesh* :

- Conversion region
  - Primary ionization
  - Charge drift towards A.R.
- Amplification region
  - Charge multiplication
  - Readout layout
    - Strips (1/2 D)
    - Pixels

➔ Very strong and uniform electric

- metallic micromesh (typical pitch 50µm)
- sustained by 50-100 µm pillars
- simplicity
- single stage of amplification
- fast and natural ion collection
- discharges non destructive

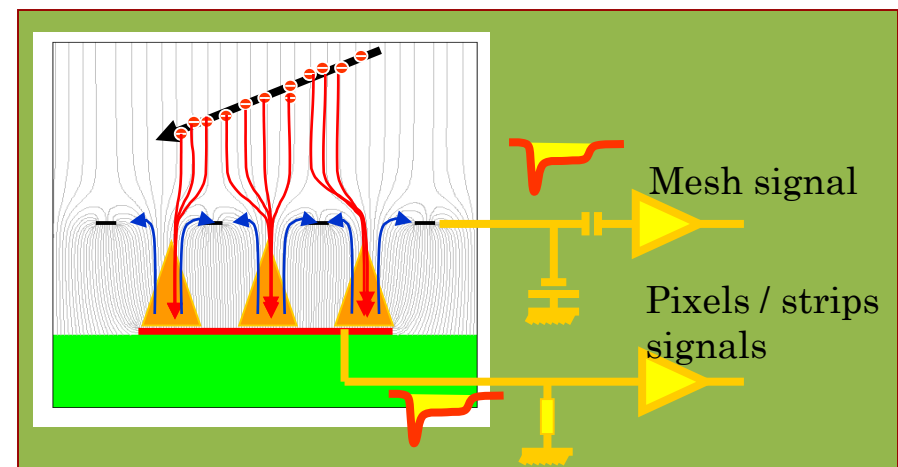
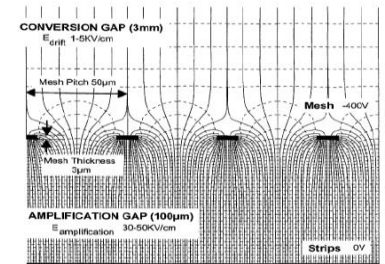


## MICROMesh Gaseous Structure Giomataris, Charpak (1996)

Y. Giomataris et al., NIM A 376 (1996) 29

*In 1st Micromegas*

*Fishing line spacers have been used*

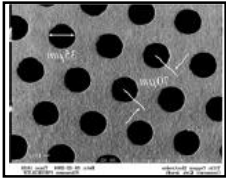


# The Micromegas detector

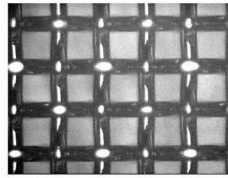
## Micro-mesh (cathode)

The metallic micro-mesh must be 5 to 30 mm thick with needed equivalent wires densities ranging from 500 to 2000 Lines Per Inch (LPI). Stainless steel woven meshes, electroformed Nickel meshes, or chemically etched copper meshes are used.

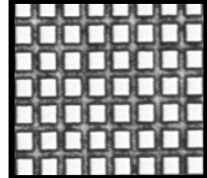
Chemically etched Copper mesh



500 LPI 304L woven mesh

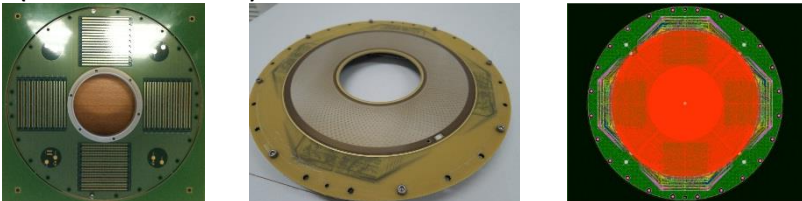


500 LPI Electroformed Ni mesh



## Printed Circuit Board (anode PCB)

- It can be up to 1- 3 m<sup>2</sup> and down to 100 μm thin.
- Copper strips or pads can be ≈100 μm to few mm large and insulation between them as low as 50 μm.
- Copper is usually covered by a Ni/Au layer for a total thickness which must be kept as low as possible (down to 5 mm) with a « smooth » surface.

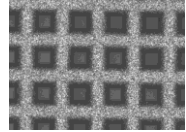


A Φ30 cm 12 layers PCB with 4000 x 4 mm<sup>2</sup> pads for the MINOS TPC (18000 blind vias)

## Drift electrode + neutron converter

- For **thermal neutrons**, it can be a thin aluminum foil or a metallic mesh covered by a 1-2 mm thick layer containing <sup>10</sup>B (such as B<sub>4</sub>C) or by a ≈100 mm thick <sup>6</sup>Li layer.

An electroformed Ni mesh covered by a 2 μm thick B<sub>4</sub>C layer (Linköping Univ.)



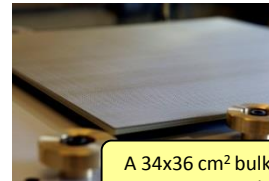
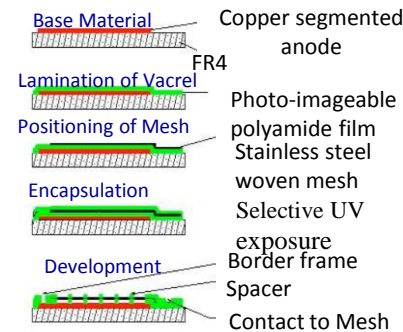
- For **high energy neutrons**, a few mm thick polyethylene (CH<sub>2</sub>) sheet is used.

## Micromegas technologies

to realize the micro-mesh + anode PCB assembly

### Bulk-micromegas

Embedding of the mesh between two layers of insulating pillars by use of photolithography technics

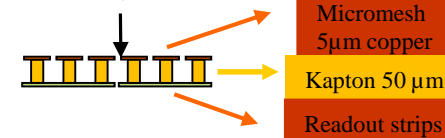


A 34x36 cm<sup>2</sup> bulk-micromegas (T2K/TPC)

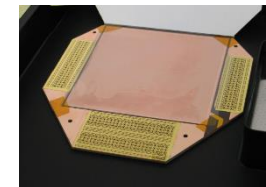
### micro-bulk micromegas

Micromegas is built from a double sided copper clad kapton foil by selective chemical etching of copper (mesh and anode strips) and kapton (insulating pillars).

Mesh with typical Φ40 μm hole with 100 μm pitch



A 10x10 cm<sup>2</sup> micro-bulk (NEXT prototype)



# Neutron detection with Micromegas

## Neutron detection → neutron to charge converter

- Solid converter: thin layers deposited on the drift or mesh electrode ( $^{10}\text{B}$ ,  $^{10}\text{B}_4\text{C}$ ,  $^6\text{Li}$ ,  $^6\text{LiF}$ , U, actinides...)

- ✓ Sample availability & handling
- ✓ Efficiency estimation
- ✗ *Limitation on sample thickness from fragment range*  
⇒ *limited efficiency*
- ✗ Not easy to record all fragments

- Detector gas ( $^3\text{He}$ ,  $\text{BF}_3$ ...)

- ✓ Record all fragments
- ✓ No energy loss for fragments ⇒ reaction kinematics
- ✓ No limitation on the size ⇒ high efficiency
- ✗ *Gas availability*
- ✗ Handling (highly toxic or radioactive gasses)

- Neutron elastic scattering

- gas (H, He)
- solid (paraffin etc.)
  - ✓ Availability
  - ✓ High energies
  - ✗ Efficiency estimation & reaction kinematics

## Neutron detection with high efficiency (~50%):

- $^3\text{He}$  crisis
- Increased demand for neutron detectors
  - ➔ Science
  - ➔ Homeland security
  - ➔ Industry

## Micromegas for neutrons

- Micro-Pattern Gaseous Detector (gain, fast timing, high rate, granularity, radiation hardness, simplicity...)
- Low mass budget
- Transparent to neutrons
- Large area detectors cheap & robust

# The multilayer concept

- A boron layer thicker than 1-2  $\mu\text{m}$  is **not efficient** due to the **absorption** of the reaction products
- Maximum efficiency that can be achieved in this case is of the order of **4-5 %**

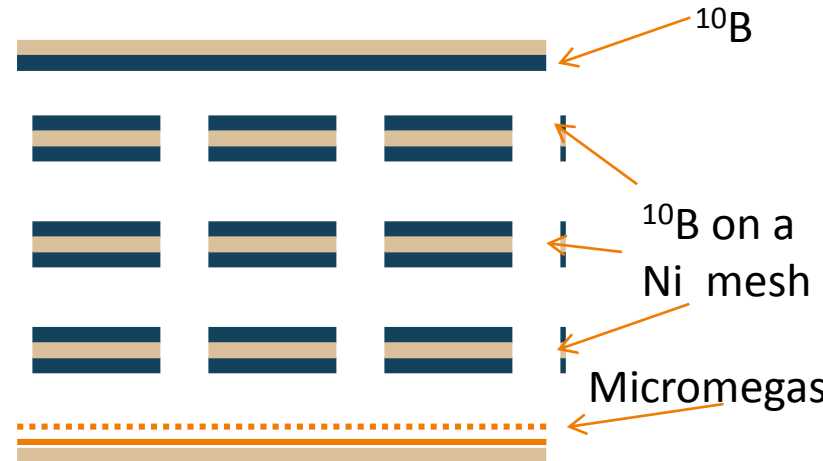
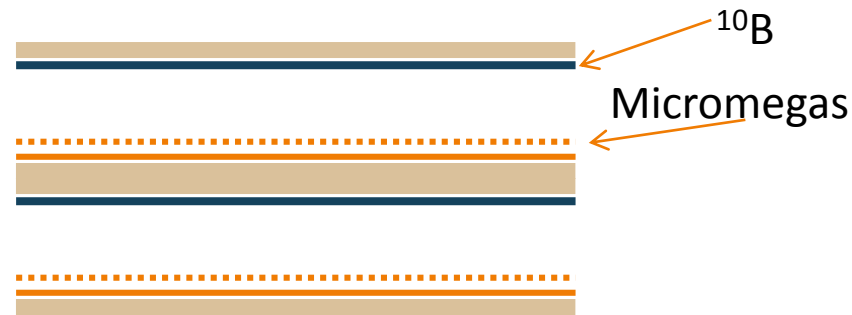
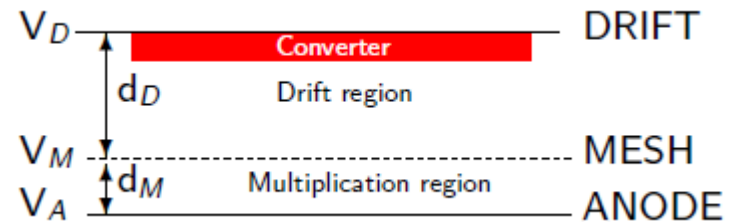
✓ **One solution: a tower of detector-converter layers**

- ➔ Many detectors
- ➔ Lots of material

✓ **Alternative: a tower of converter layers for each detector:  $^{10}\text{B}$  deposited on thin metallic meshes**

- ➔ Less electronics
- ➔ Less material

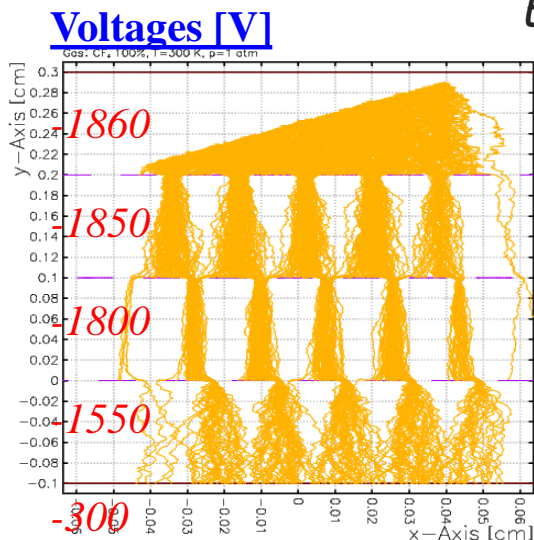
Difficulty: drift the produced charges to the detector through the mesh holes (proper configuration of the electric field)



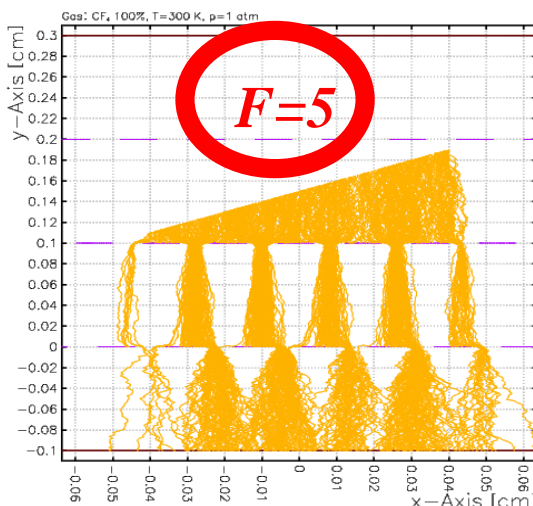


# Simulation of a 7-layer unit

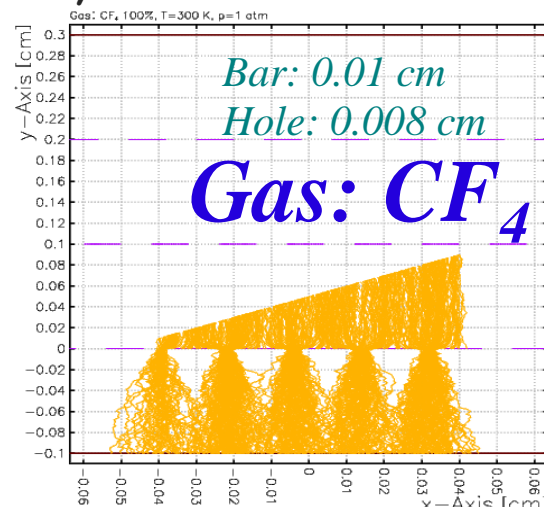
Electrons collection efficiency - Garfield simulations



35%

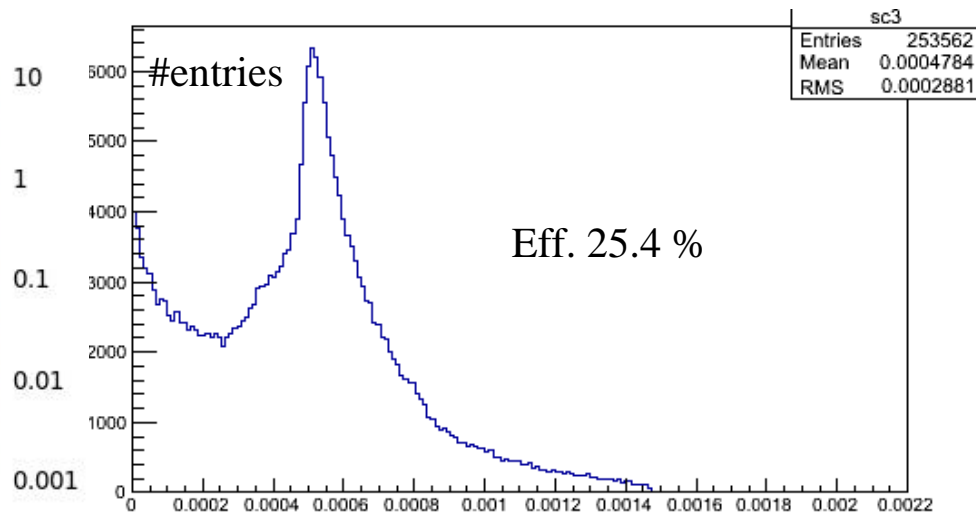
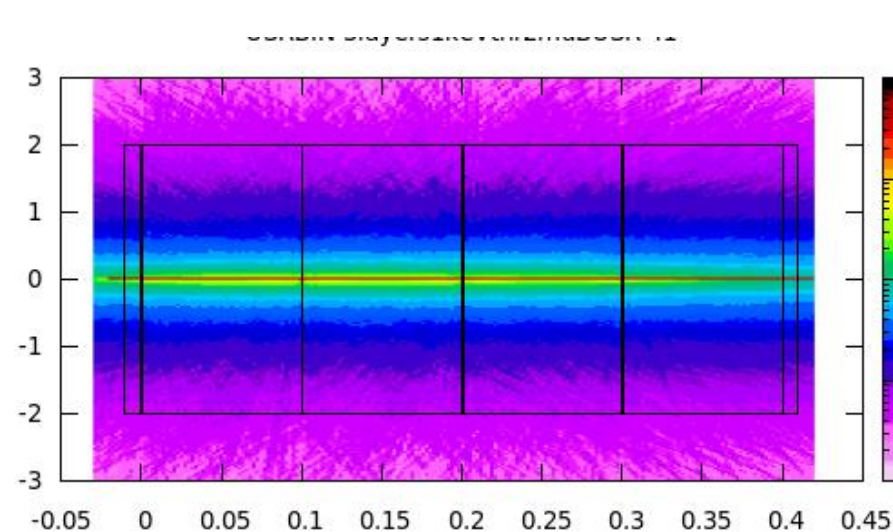


53%



77%

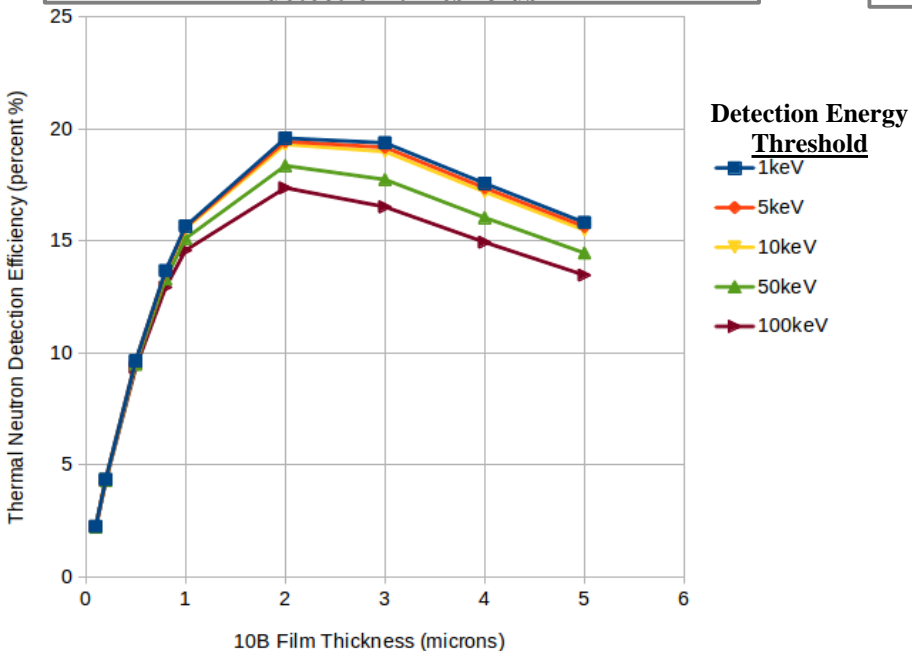
*Perpendicular beam on the Al frame with  $E_n = 0.025$  eV,  $E_{th} = 1$  keV,  $2\mu\text{m}$  B<sub>4</sub>C – 7 layers,  $1E6$  primaries*



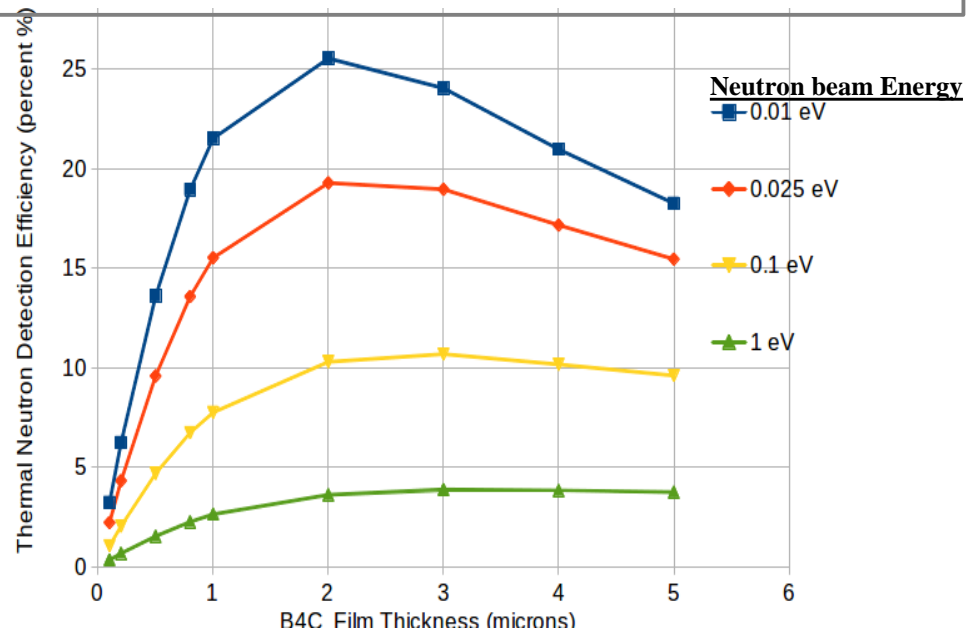
# Efficiency

1 unit with  $5 \times 10^4 \text{B}_4\text{C}$  layers

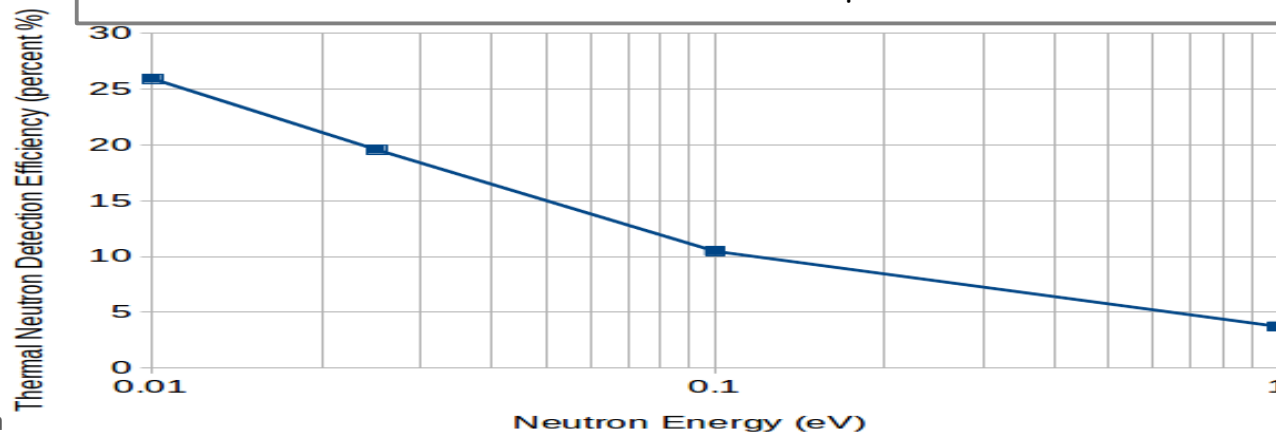
Thermal Neutron Detection Efficiency for various detection thresholds



Neutron Detection Efficiency for various neutron beam energies with detection threshold at 10 keV

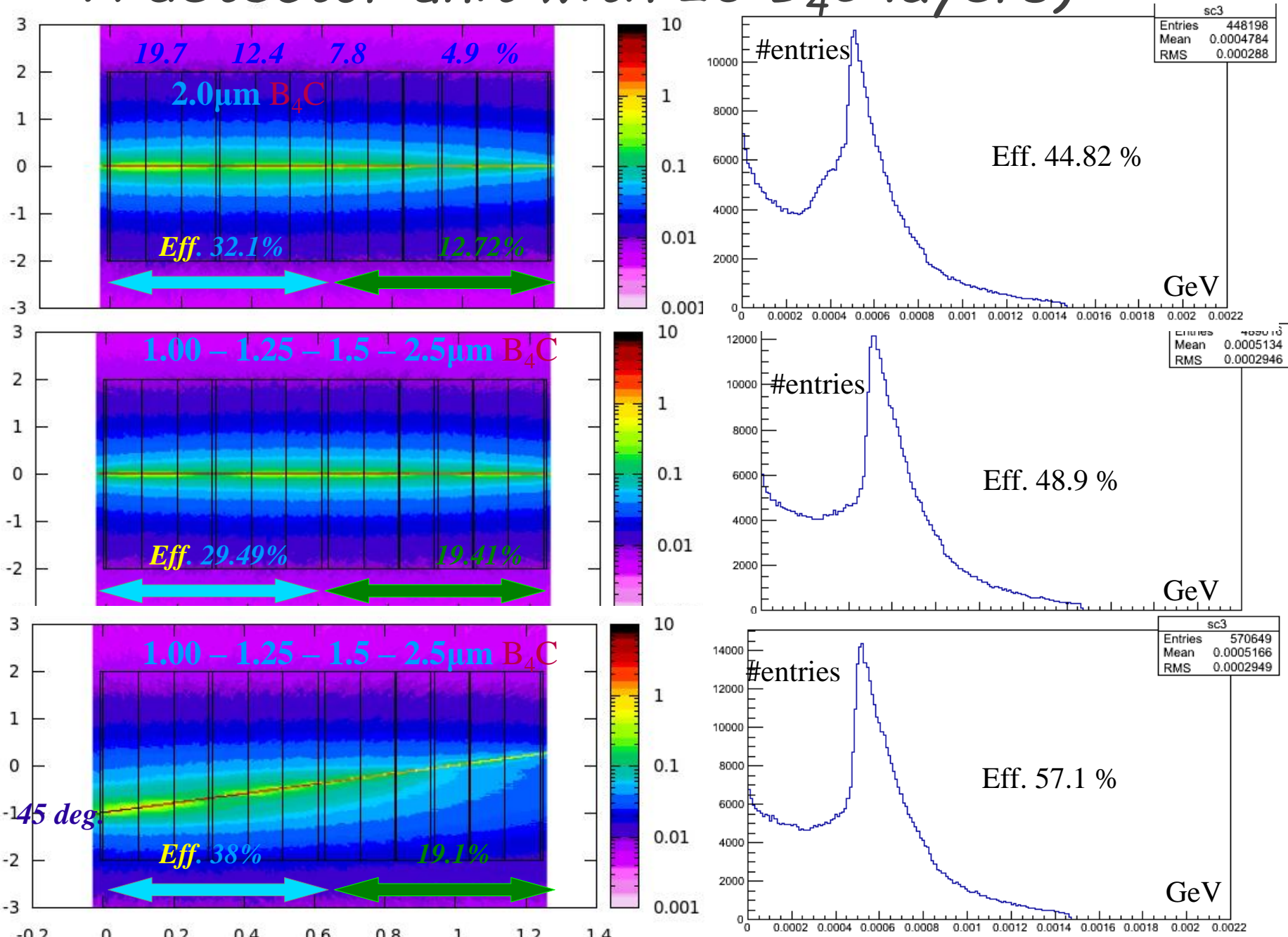


Thermal Neutron Detection Efficiency for various neutron beam energies with detection threshold at 1 keV and thickness of B4C at  $2\mu\text{m}$



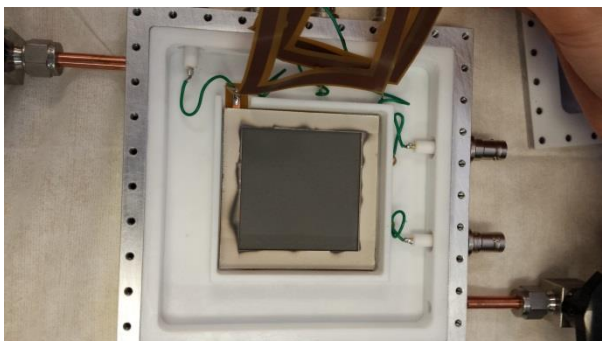
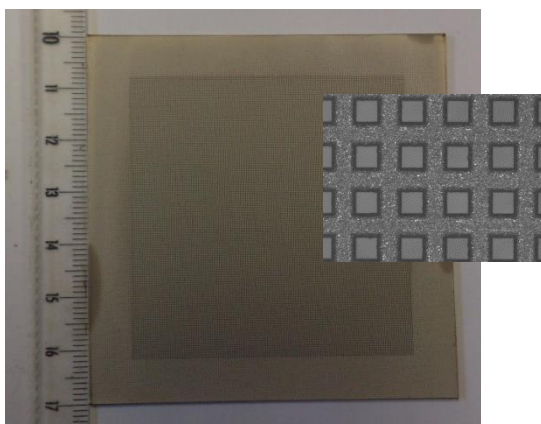
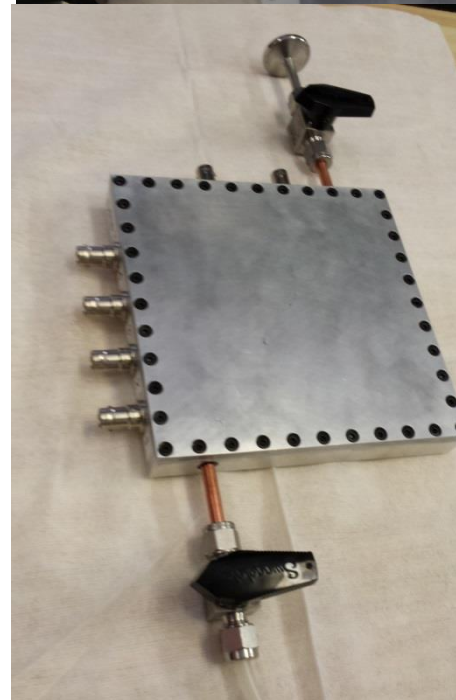
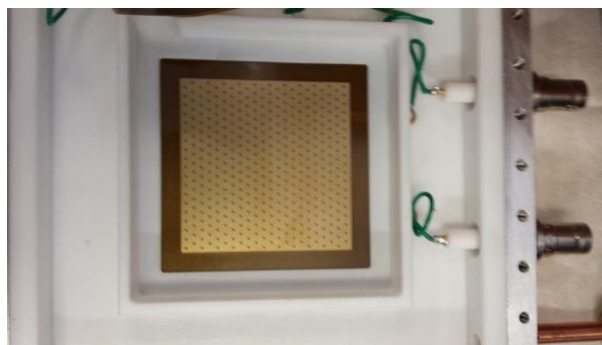
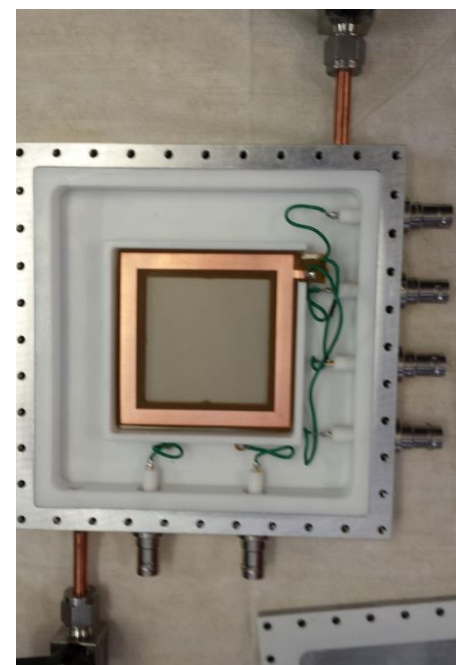


# A detector unit with 20 $B_4C$ layers)



# The Micromegas prototype

- Bulk Micromegas 5x5 cm<sup>2</sup>
- Ni frames 7x7 cm<sup>2</sup>
- Ni meshes 10% & 20% transparent
- Voltages applied with the help of kapton+Cu frames
- *Ni meshes double coated with 1.5 μm B<sub>4</sub>C layers*
  - 10% - 20% transparent
  - 5, 20, 120 μm thick
  - 50, 100, 500, 1000 LPI*(Linköping University)*



# 5-layer prototype performance

A single 2-mesh detector unit →  $F=7$ ,  $5 \times B_4C$  layers

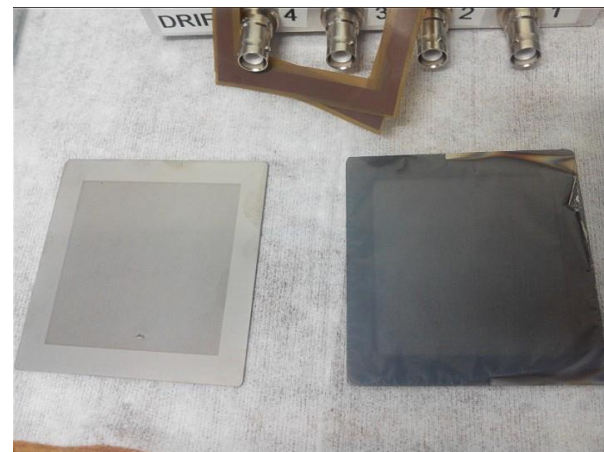
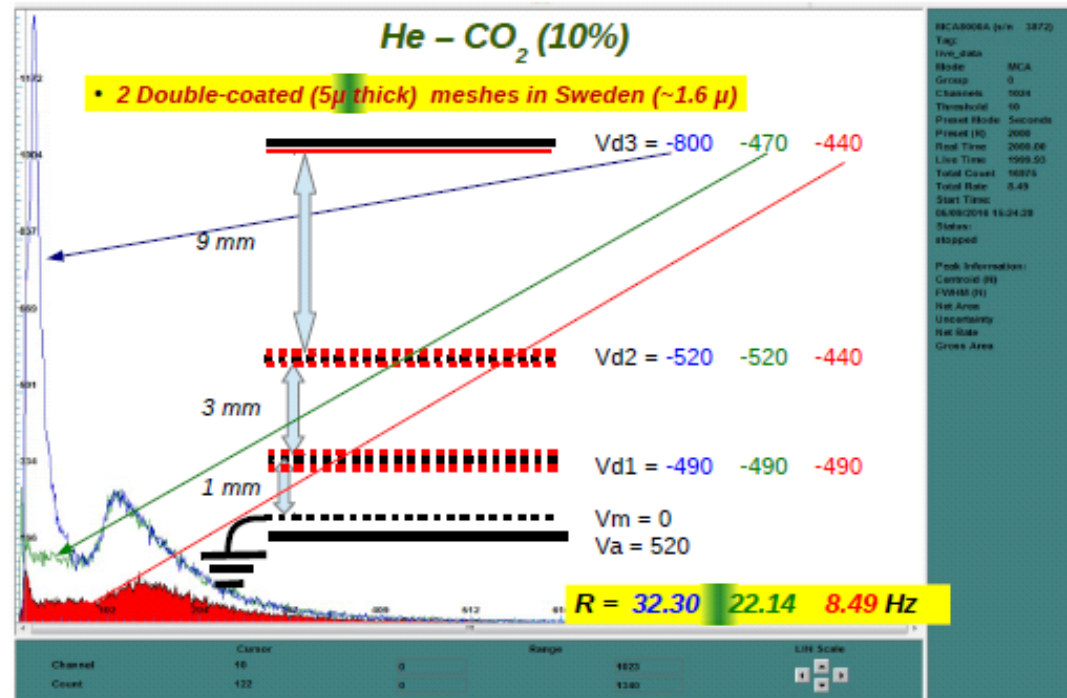
Comparison with commercial  $^3\text{He}$  tube:

Count rate  $\{^3\text{He} / \text{MM}\} = 5.5$   
 Assuming  $^3\text{He}$  eff.  $\sim 95\%$   
 →  $\text{MM eff} \sim 18\%$

Satisfactory result

but:

- Electron transmission too low when mesh thickness  $\gg 5 \mu\text{m}$
  - Mesh deformed during  $B_4C$  deposition if thickness  $\ll 20 \mu\text{m}$
- Difficult to operate with more than 3 layers per unit with large area Ni meshes



# Alternative 1: Kapton mesh (GEM-type)

12.5  $\mu\text{m}$  Kapton mesh

- double-side coated with 3-4  $\mu\text{m}$  Cu
- double-side coated with 1  $\mu\text{m}$  Ni
- double-side coated with 1.5  $\mu\text{m}$   $\text{B}_4\text{C}$

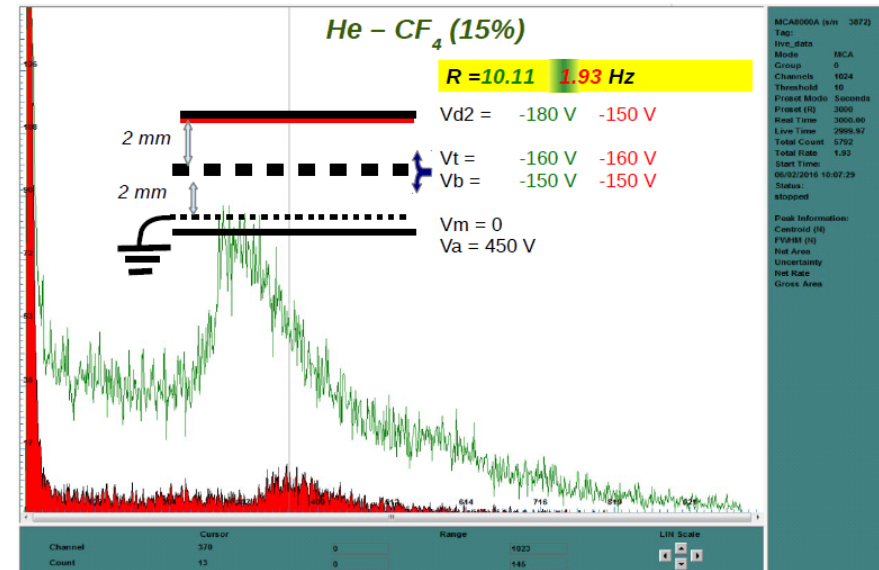
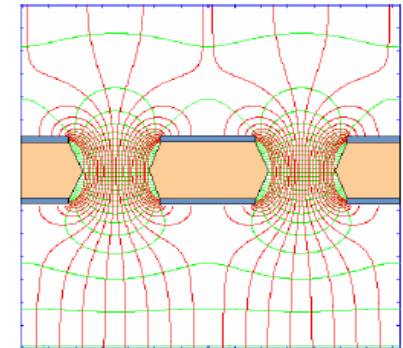
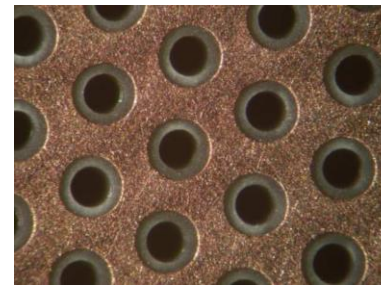
$\Delta V$  (10-50 V) applied between the two Cu layers  
 $\rightarrow$  electric field strong enough for sufficient electron transmission

- Small voltage for top layer ( $< 500$  V)
- Small amplification possible to compensate electron losses (factor 2-3)

- ✓ Mesh is cheap and robust
- ✓ Big surfaces possible ( $1 \times 0.5 \text{ m}^2$ )



GEM-type kapton mesh



# Alternative 1: Kapton mesh (GEM-type)

## 12.5 $\mu\text{m}$ Kapton mesh

- double-side coated with 3-4  $\mu\text{m}$  Cu
- double-side coated with 1  $\mu\text{m}$  Ni
- double-side coated with 1.5  $\mu\text{m}$   $\text{B}_4\text{C}$

$\Delta V$  (10-20 V) applied between the two Cu layers  
→ electric field strong enough for sufficient electron transmission

- Small voltage for top layer ( $< 500$  V)
- Small amplification possible to compensate electron losses (factor 2-3)

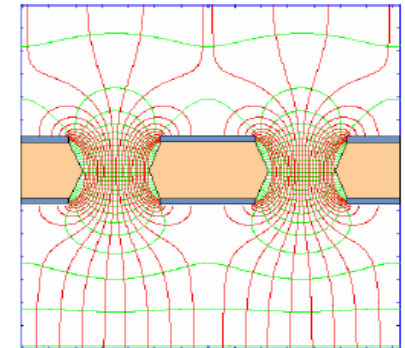
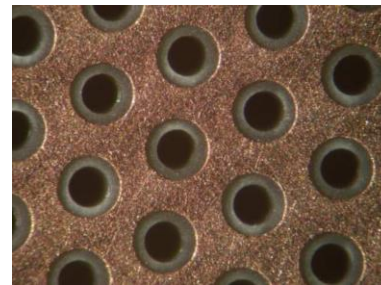
- ✓ **Mesh is cheap and robust**
- ✓ **Big surfaces possible (1×0.5 m<sup>2</sup>)**

Problem with  $\text{B}_4\text{C}$  deposition: thermal expansion.

- Use pure  $^{10}\text{B}$
- Use a transparent mask (micromesh) during deposition of  $\text{B}_4\text{C}$

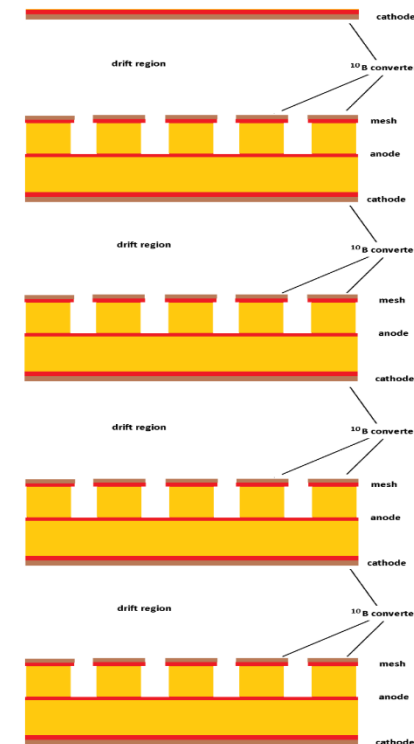
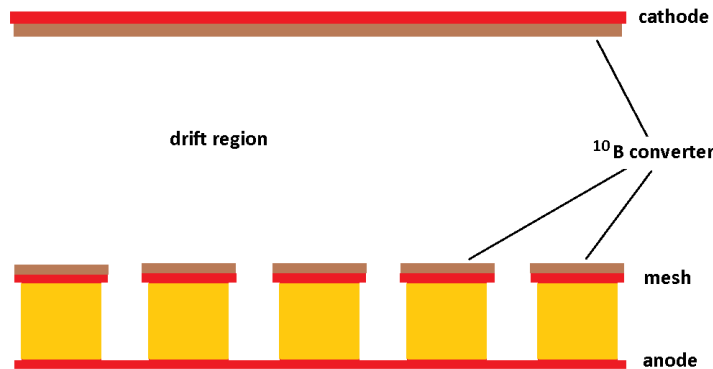
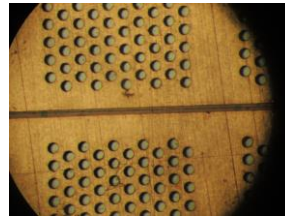


GEM-type kapton mesh



# Alternative 2: Microbulk stack

- Microbulk is also a Kapton mesh, Cu-coated.
- Boron can be deposited on the Microbulk surface  
➔ double efficiency
  - Ni or Au coating needed
  - ✗ Same problem from thermal expansion coefficients
- Units can be stacked without limitation, using only 3 voltages (same cathode, mesh, anode voltages)
- ✓ Unit can be very thin (~1 mm)
- ✓ Low material budget
- ✓ Common / independent readout possible



•  
•  
•

# Summary

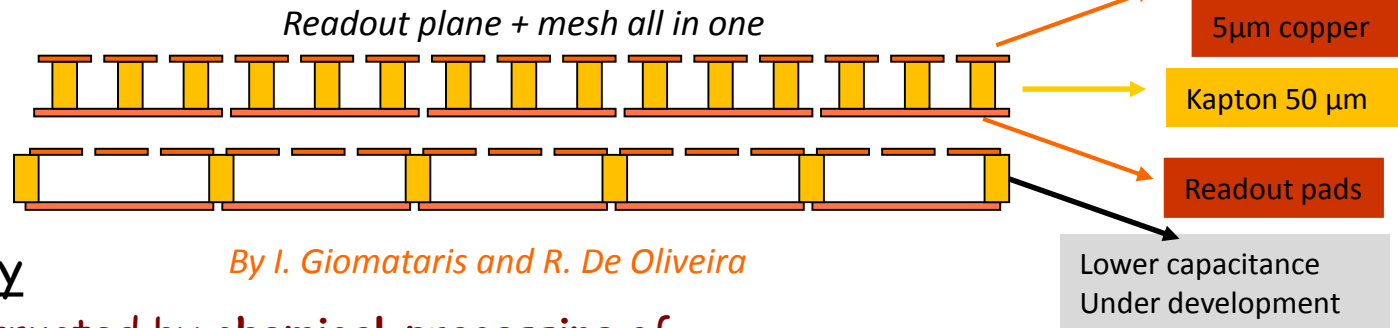
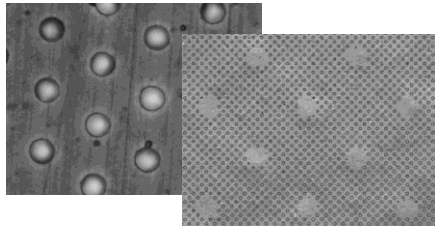
We are examining possible ways to increase the detection efficiency for thermal neutrons, using solid neutron-to-charge convertors:

- **A Micromegas equipped with several metallic (Ni) thin meshes coated with  $B_4C$  in both sides**
  - ✓ Efficiency improvement as expected by the simulations
  - × Small electron transmission for thick (robust) meshes
  - × Deformation & fragility for thin meshes. Problem for large surface detectors
- **A Micromegas equipped with GEM-type meshes coated with  $B_4C$  in both sides**
  - ✓ Good electron transmission. Amplification during transmission easy
  - ✓ Small voltages
  - ✓ Robustness. Large surface detectors possible with low cost
  - × Deposition of  $B_4C$  on the foil is difficult. Under study
- **A stack of Microbulks coated with  $B_4C$** 
  - ✓ Low material, thin detector
  - × Deposition of  $B_4C$  on the foil is difficult. Under study.

*Thank you!*



# Microbulk Micromegas technology



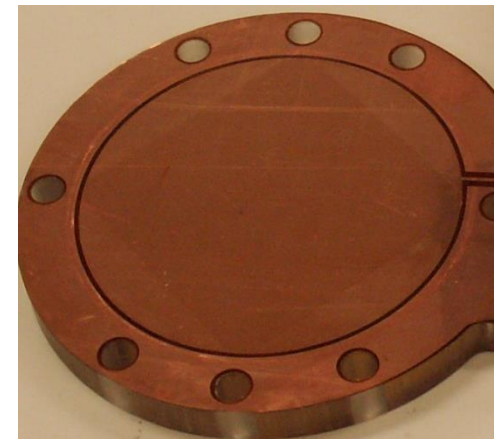
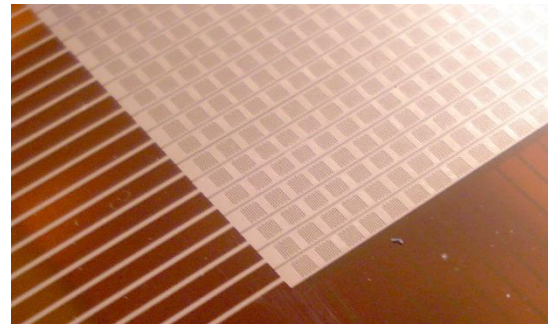
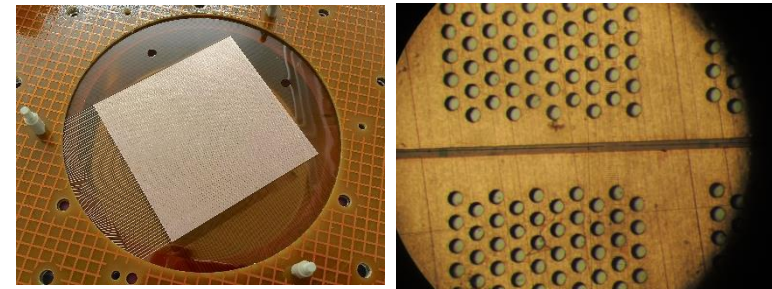
By I. Giomataris and R. De Oliveira

## Microbulk Technology

The pillars are constructed by **chemical processing of a kapton foil**, on which the mesh and the readout plane are attached. **Mesh is a mask for the pillars!**

Typical mesh thickness 5  $\mu$ m, gap 50/25  $\mu$ m

- ✓ Energy resolution (down to 10% FWHM @ 6 keV)
- ✓ Low intrinsic background & better particle recognition
- ✓ Low mass detector
- ✓ Very flexible structure
- ✓ Long term stability
- ✗ Higher capacity
- ✗ Fabrication process complicated
- ✗ Fragility / mesh can not be replaced



# The "real XY structure"

Bulk Micromegas are too massive to be in a neutron beam in parallel with x-section measurements

X-Y Microbulks are quite massive compared to the single-anode ones

A permanent profiler (+flux monitor!) would be useful for n\_TOF EAR1 & EAR2, NFS, GELINA

**RD51 Project, 15kE for CEA, UniZar & Demokritos:**  
"real" X-Y microbulk by mesh segmenting

## Motivation:

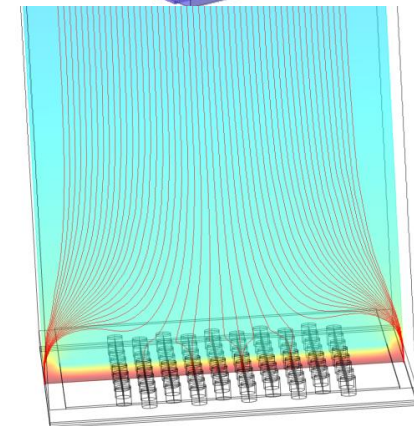
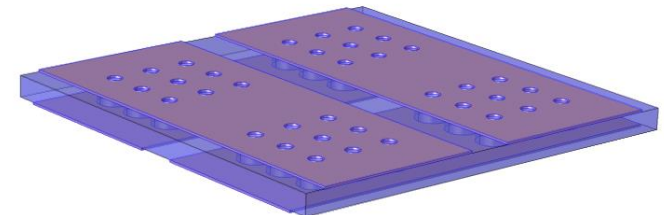
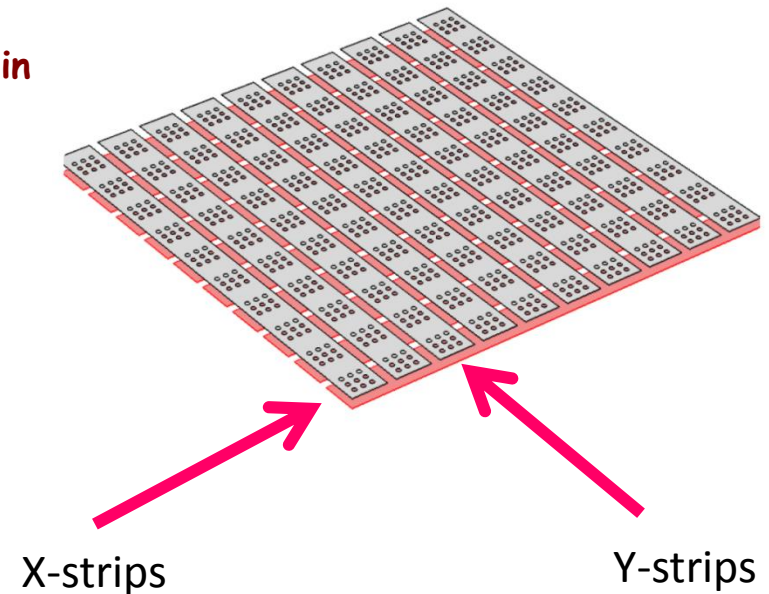
- ✓ Microbulk production simplification
- ✓ Mass minimization
- ✓ Large surfaces with high radiopurity possible

## Ideal for:

- Low mass neutron beam profilers/detectors
- Large area low background detector

## Challenges:

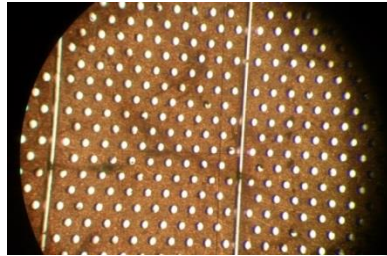
- **No common mesh signal to use as event trigger.**  
The strips information has to be used for that purpose.
- **Special readout electronics should be used for the mesh strips**
- **Special circuitry for providing the mesh-strips HV should be built.**



# XY Prototype evolution

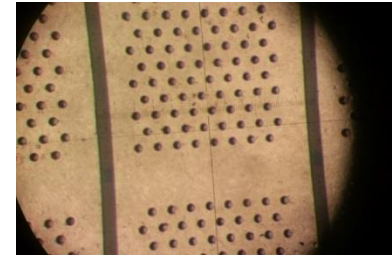
## First batch:

- ✗ Problems during etching due to holes topology.
- ✗ Many strips in short circuit.



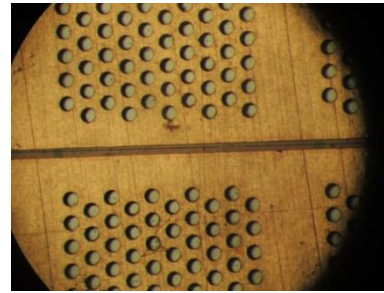
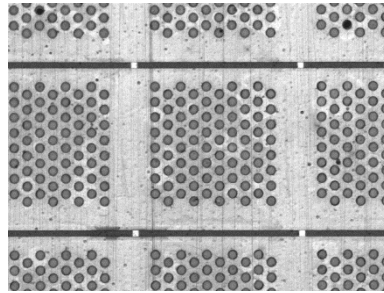
## Second batch

- Etching OK with the new topology
- All detectors working
- ✗ Bad energy resolution due to large gaps (~150  $\mu\text{m}$ )



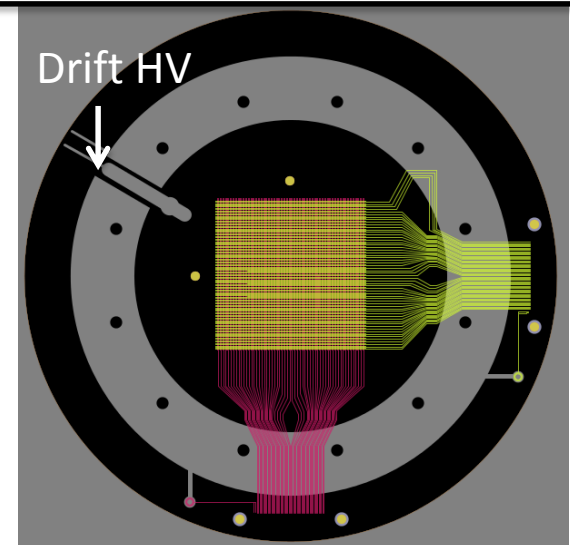
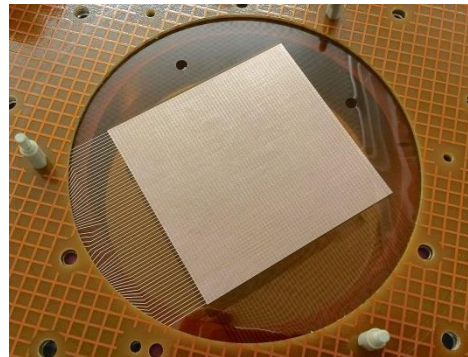
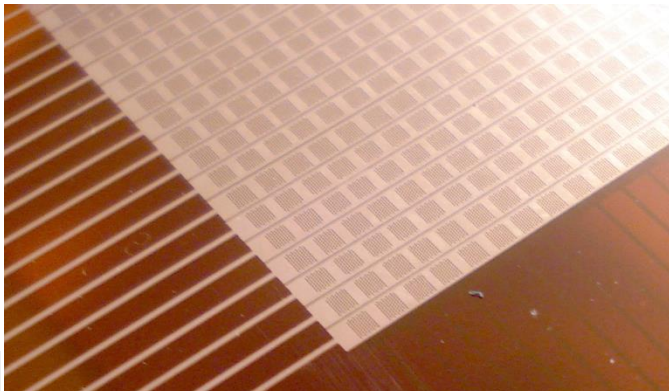
## Third batch

- Holes  $\varnothing$  60/50  $\mu\text{m}$
- Gaps reduced to 35  $\mu\text{m}$
- Energy resolution OK!



## The first detectors produced:

- 58 x 59 strips on a 6 x 6cm<sup>2</sup> area (**1mm** thickness)
- Mesh hole: ~ 60 $\mu\text{m}$  / Pitch: 100  $\mu\text{m}$ .



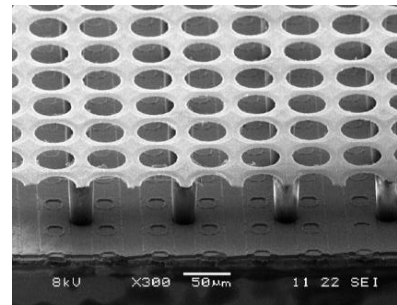
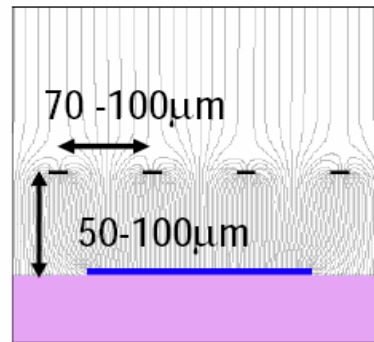
# Micro Pattern Gaseous Detectors (MPGD)

Best technology for gaseous detector readout:

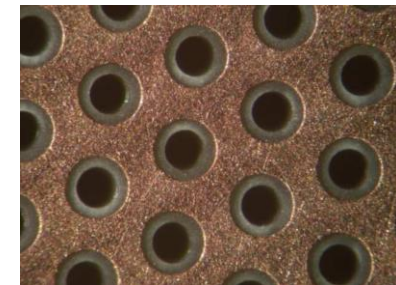
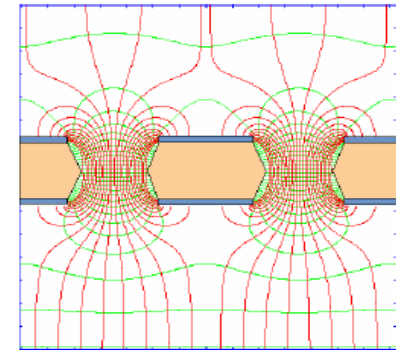
## Micro Pattern Gaseous Detectors

- high granularity
- more robust than wires
- no  $E \times B$  effect
- fast signal & high gain
- low ion feedback
- better ageing properties
- easier to manufacture
- lower cost
- big surfaces

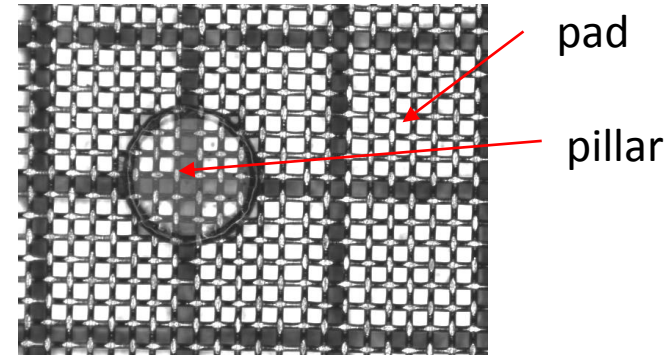
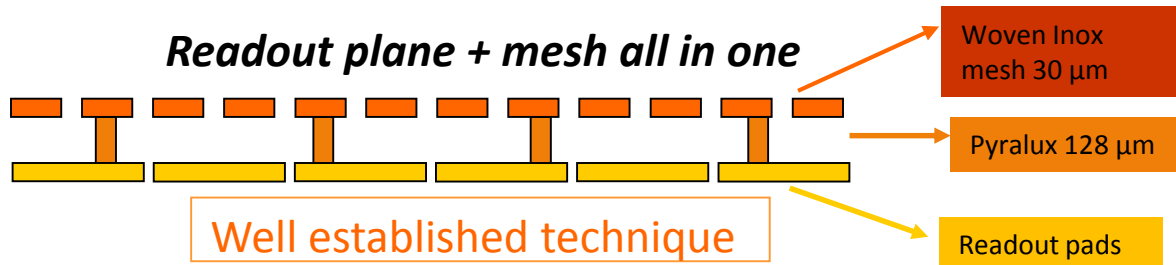
**Micromegas**



**GEMs**



# Bulk Micromegas technology

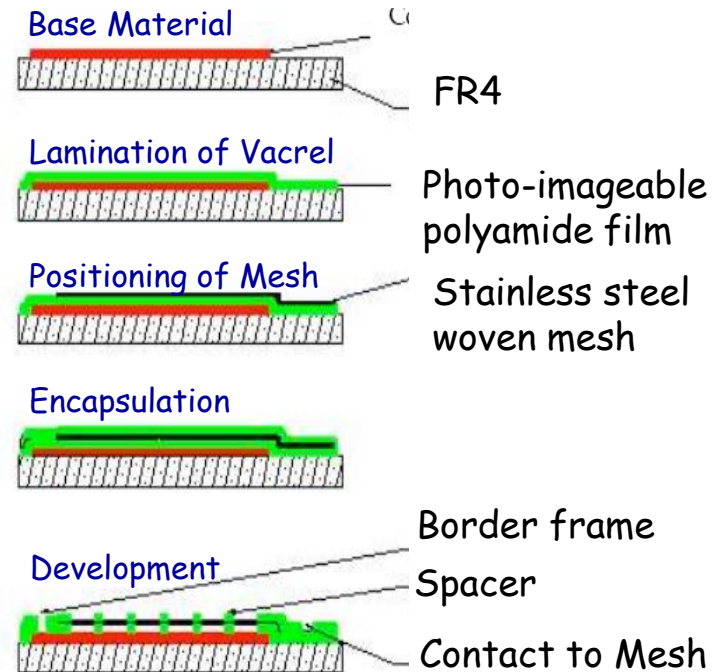


Result of a CERN-Saclay collaboration (2004)

**Process to encapsulate the mesh on a PCB  
(mesh = stretched wires)**

Motivations for using bulk Micromegas  
the mesh is held everywhere:

- the mesh is held everywhere
- robustness (closed to dust)
- can be segmented
- repairable
- **large area detectors feasible and robust!**



I. Giomataris *et al.*, NIM A560 (2006) 405

# Bulk Micromegas technology

**Bulk Micromegas:** The pillars are attached to a woven mesh and to the readout plane

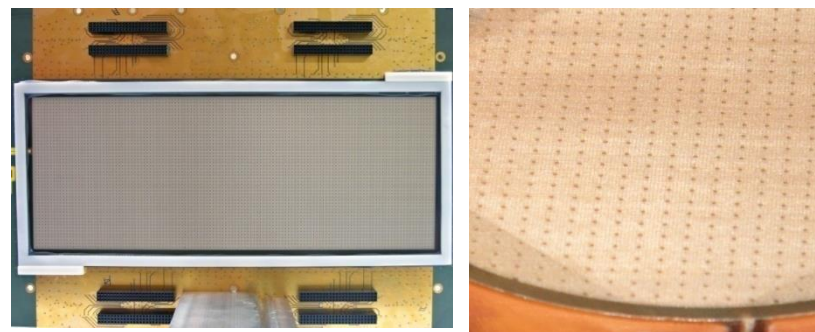
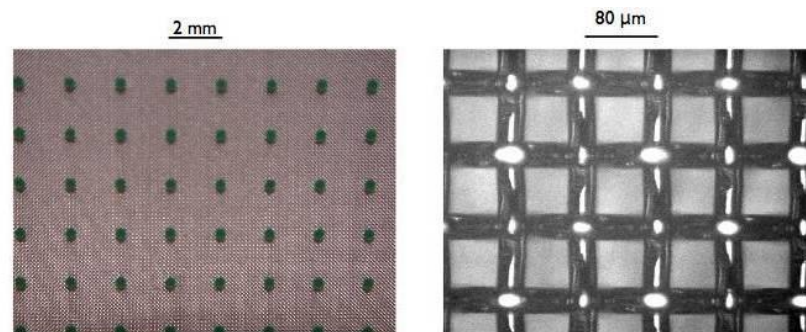
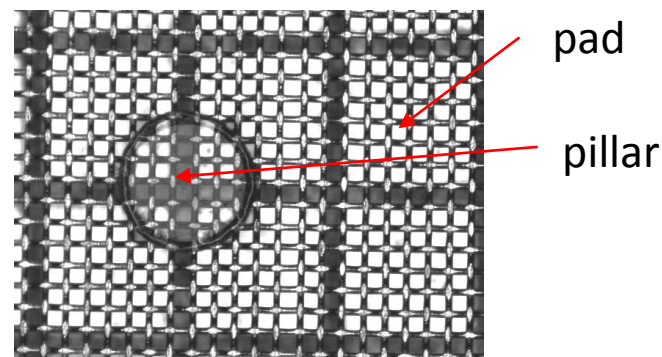
*Typical mesh thickness 30  $\mu\text{m}$ , gap 128  $\mu\text{m}$*

Uniformity, robustness, lower capacity, easy fabrication, no support frame, small surrounding dead region  $\rightarrow$

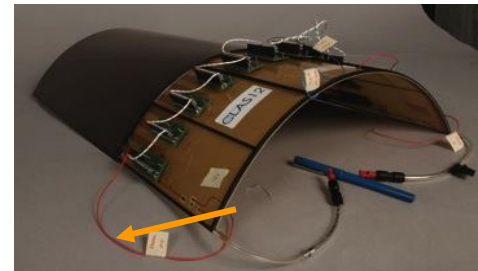
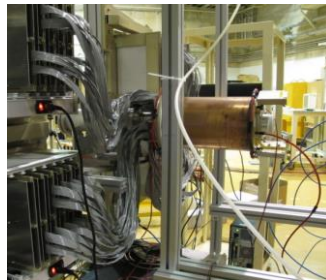
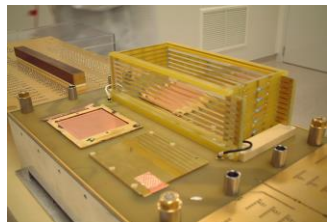
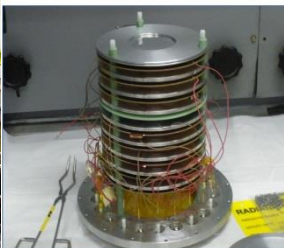
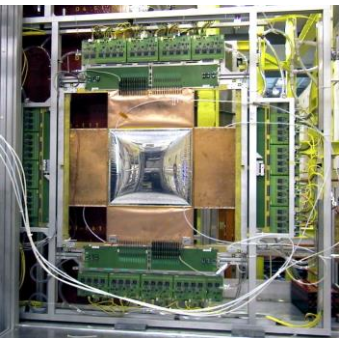
- ✓ **Large area detectors feasible and robust!**
- ✓ **Curved surfaces**
- ✓ Mass production!

*Mesh thickness & bigger gap: some disadvantages in special applications:*

- × Good but limited energy resolution ( $\sim 18\%$  @ 6keV)
- × Restrictions on materials



# Micromegas applications



COMPASS

NTOF

KABES/NA48

MINOS

CLAS12



1996

2000

2001

2003

2009

2014

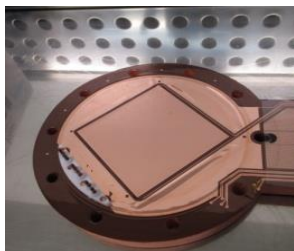
2015

2018



Micromegas  
Invention

CAST



T2K



ATLAS-NSW

